

LECTURE & TEA

Photography Beyond Realism

with Uwe Steinmueller

Sunday, September 12, 3 p.m.

\$5 Museum members, \$7 non-members



This engaging lecture will focus on both the technical and aesthetic personal choices Mr. Steinmueller makes to create lasting fine art photography. He will share the factors that have shaped and influenced his past and present work as a world-class artist.



Originally from

Germany, Uwe and his wife Bettina, with whom he shares copyright on all their work, shifted interest to digital photography in 1999. Today, they are focused on digital workflow, raw file processing and the printing process using color and black and white archival inks on large format Epson printers. As an early product tester and creator of program scripts, Mr. Steinmueller is integral in the advancing of photo imaging software. He is the author of numerous books including **Fine Art Printing for Photographers**, **The Digital Photography Workflow Handbook** and **The Art of RAW Conversion**.

There will be an opportunity for a lively Q&A period following.

The lecture begins at 3 pm.
Coffee, tea and cookies will be served.
No reservations required,
tickets available at the door.